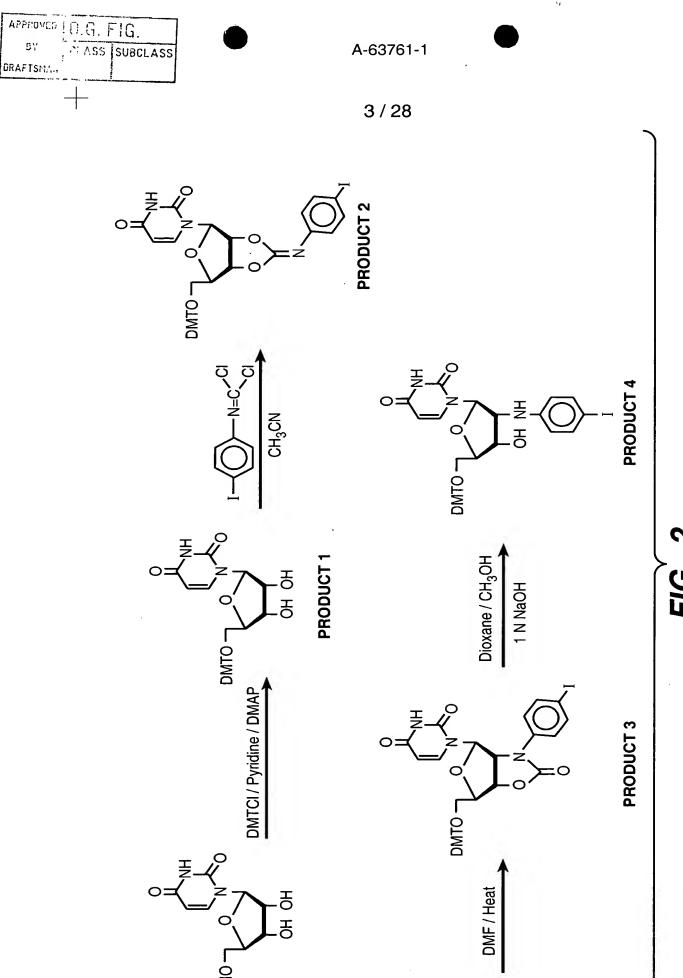
SCH<sub>3</sub>

FIG.\_1

(nBu)<sub>4</sub>NF / THF / CH<sub>2</sub>Cl<sub>2</sub>

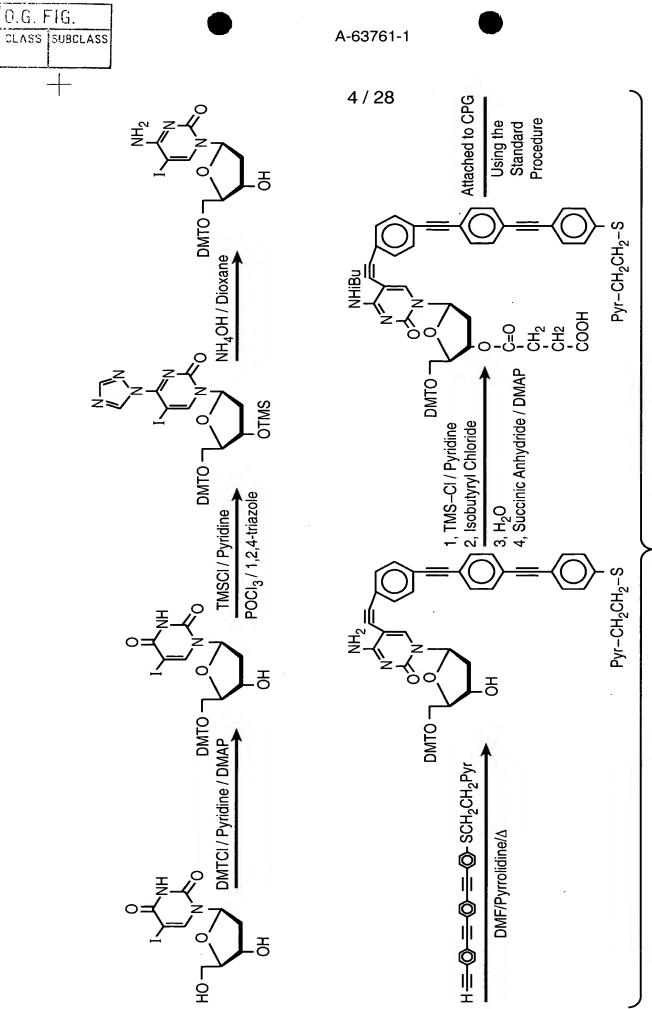
APPROVED

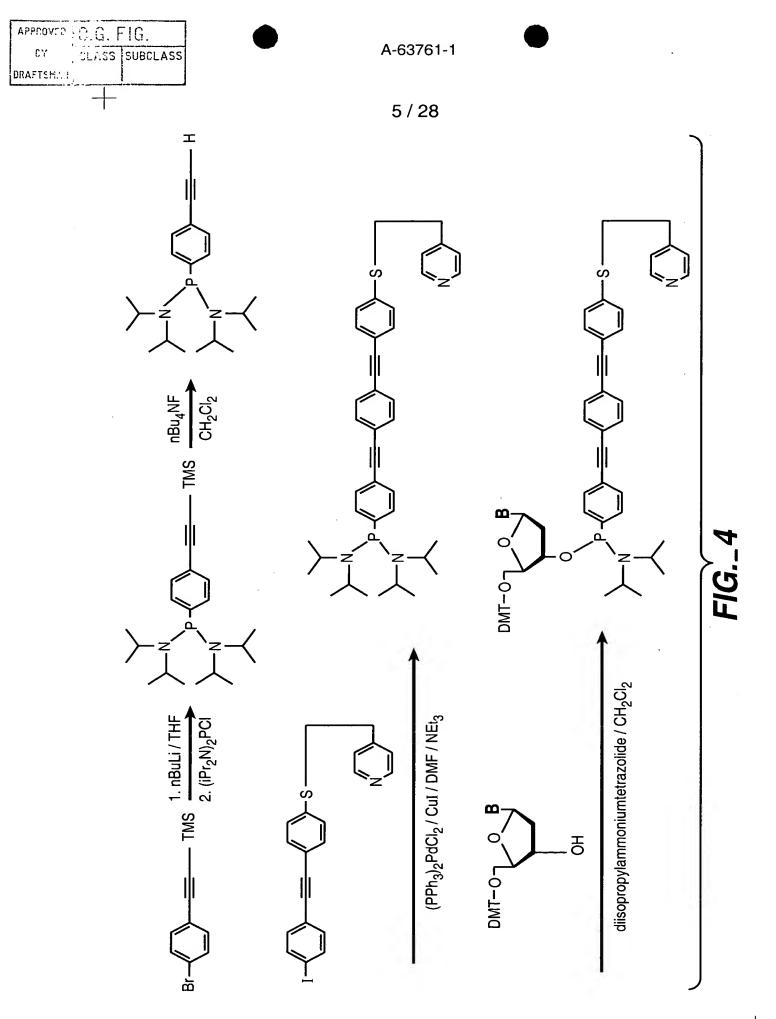
BY RAFTSMALL



PROVED

84 FISHAH



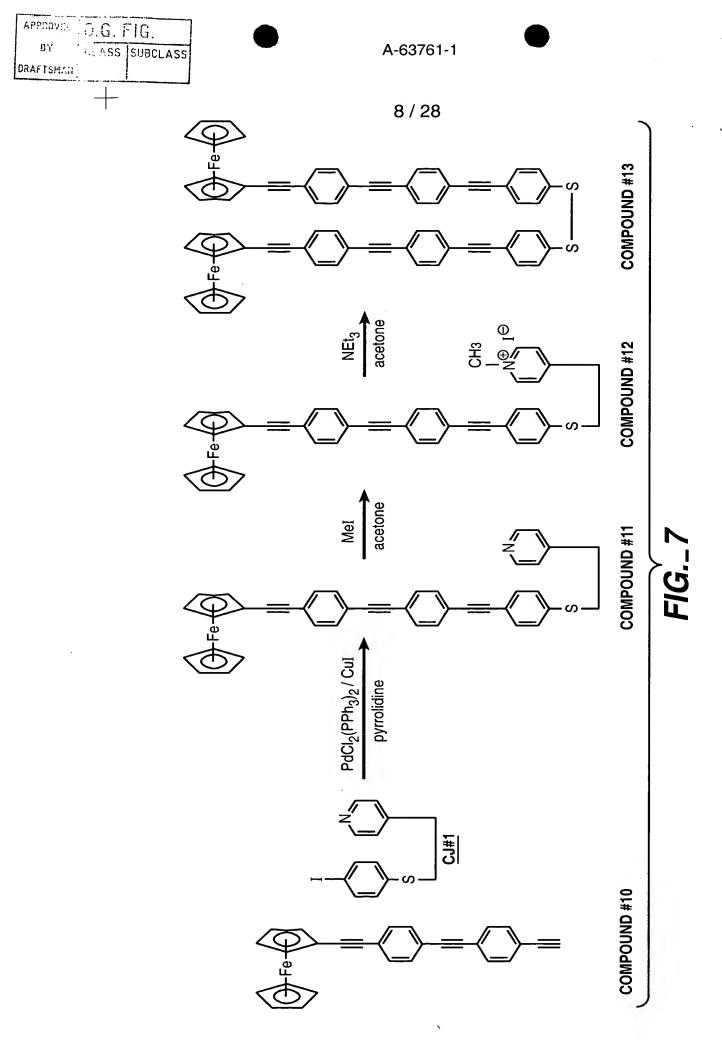


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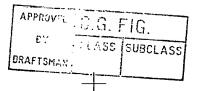
$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	$\begin{array}{c ccccccccccccccccccccccccccccccccccc$	MT-O_O-B  OH  OH	diisopropylammoniumtetrazolide / CH <sub>2</sub> Cl <sub>2</sub>	FIG5
	H———H	DMT-0-TMG	diisopropylammoni	

 $P_{\rm yCH_2CH_2S}$ 

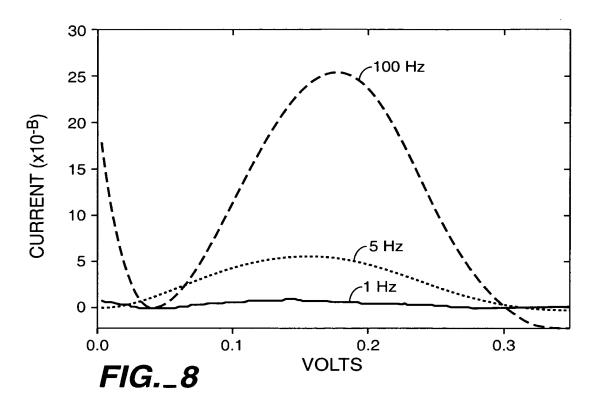
 $\top$ 

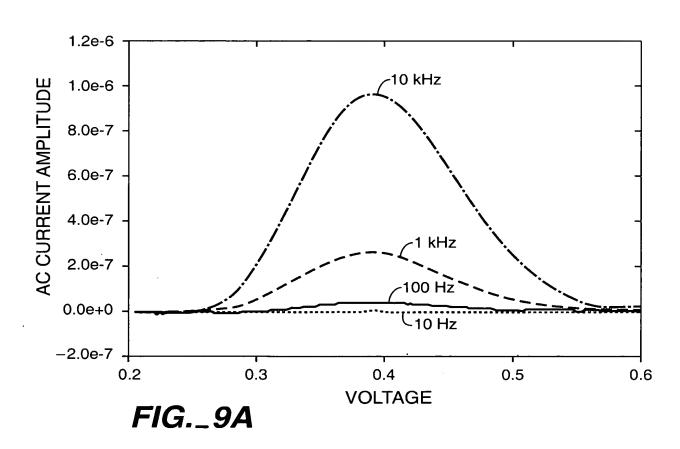


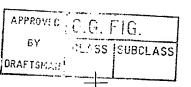
-



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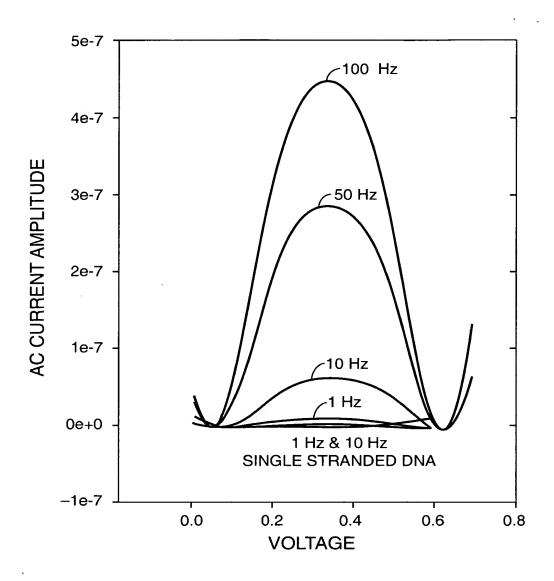
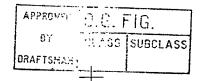
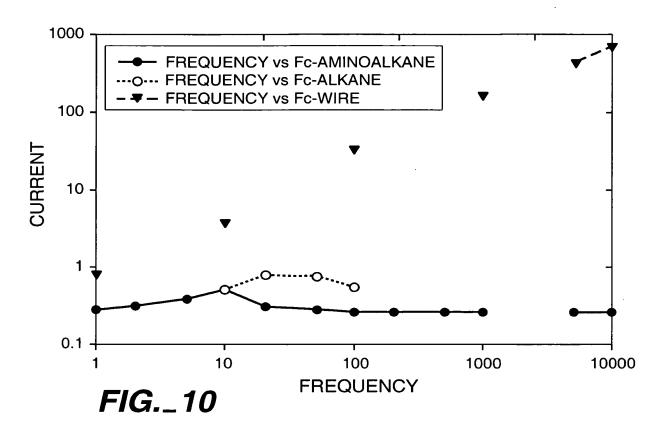
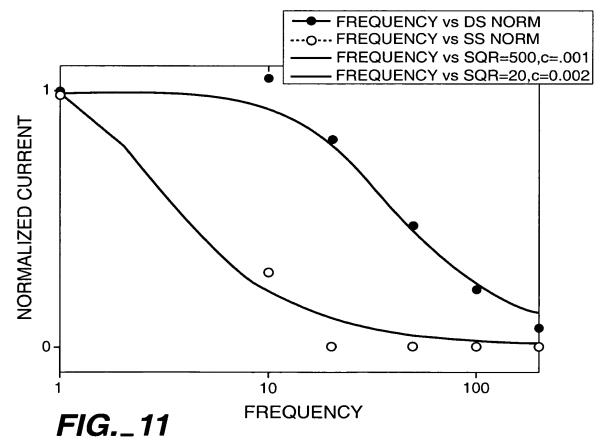


FIG.\_9B







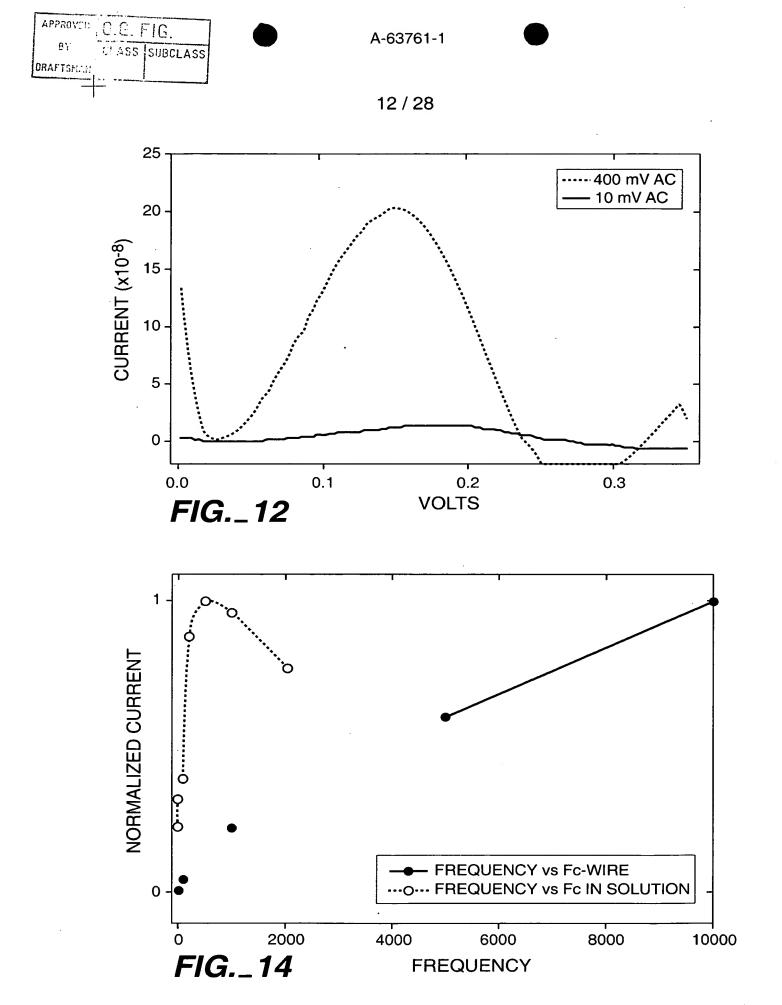


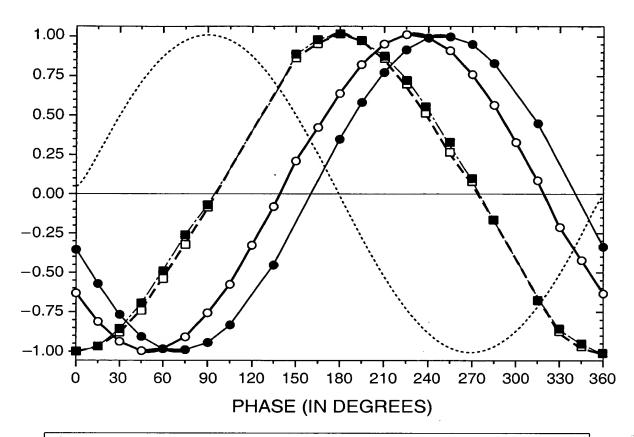
FIG.\_13B

APPROVEL O.G. FIG.

CY GLASS SUBCLASS

DRAFTSMAN:

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- -O- Fc-ALKANE + HO-INSULATOR(#1) [0213\_21] MAX @ 182 DEG.
- Fc-ALKANE + HO-INSULATOR (#2) [0213\_55] MAX @ 179 DEG.
- -D Fc-WIRE (DISULFIDE) + HO-INSULATOR, 2-STEP PROCESS [g010901]

MAX @ 230 DEG.

──── Fc-WIRE (PROTECTED) + HO-INSULATOR,

3 STEP PROCESS [g010834]

MAX @ 250 DEG.

···· DRIVING FORCE

FIG.\_15A

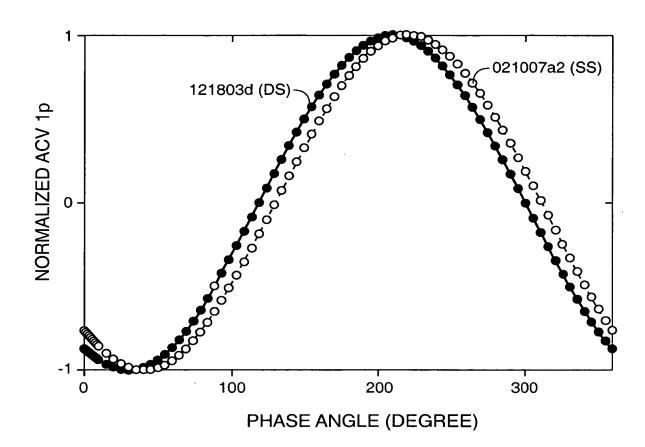
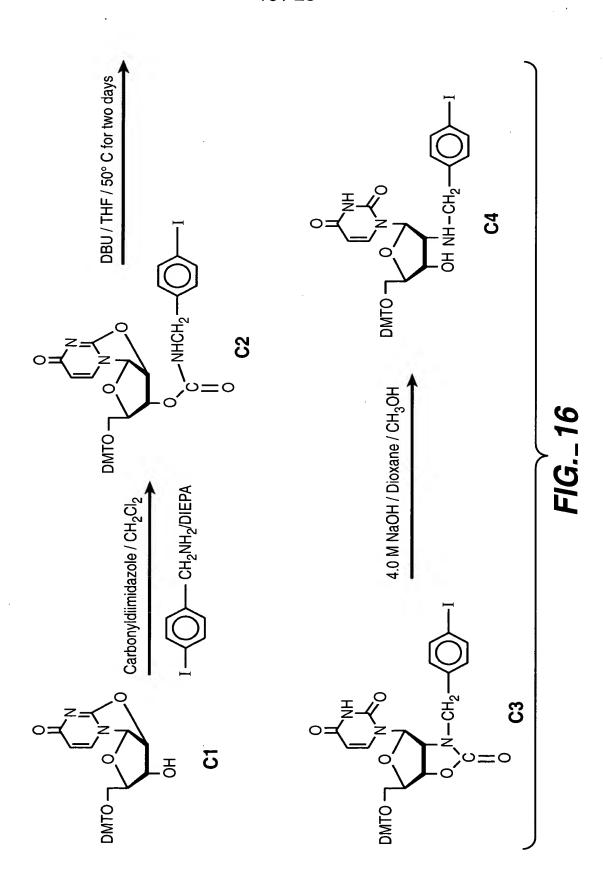


FIG.\_15B



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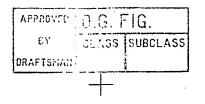
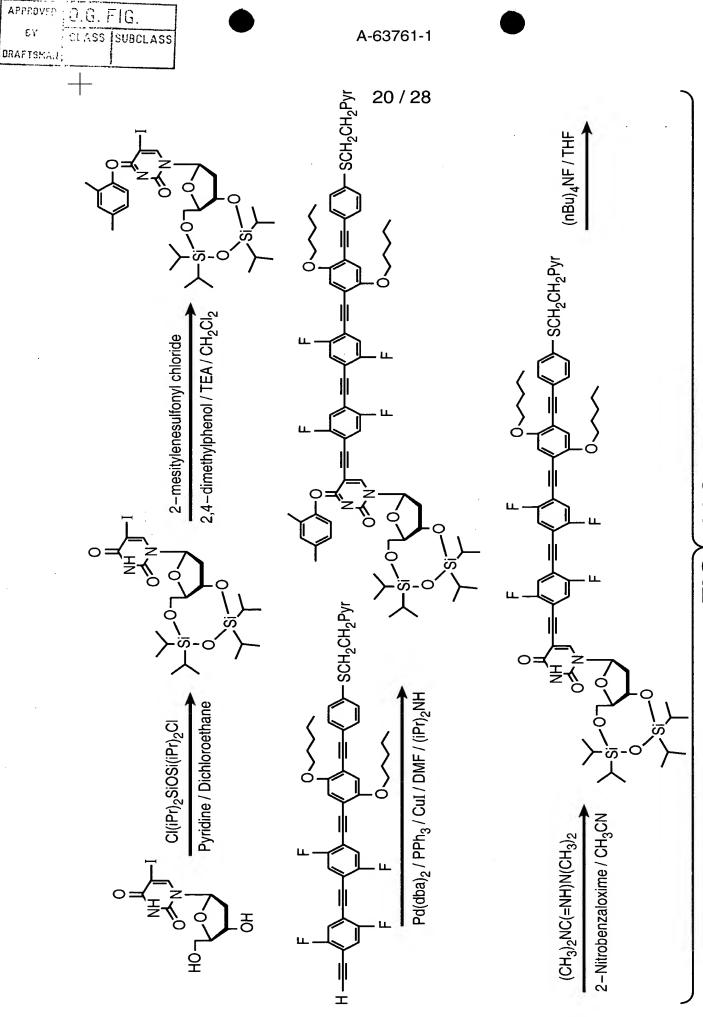
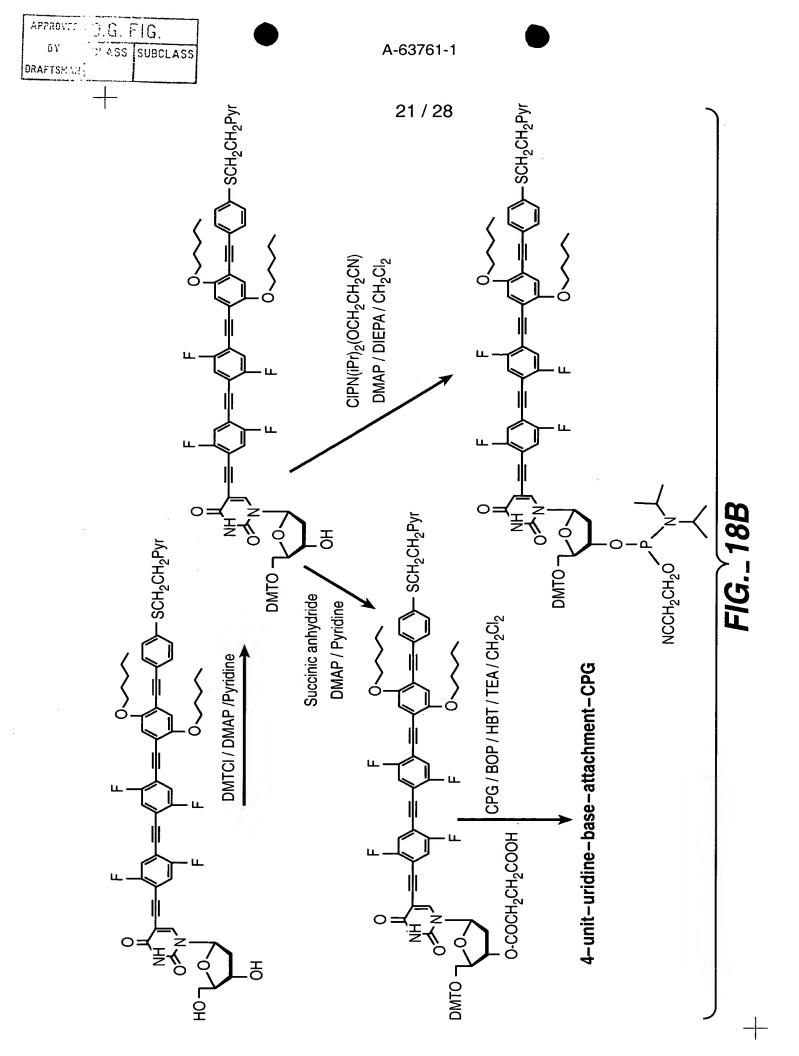


FIG.\_17F



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FIG.\_ 18A



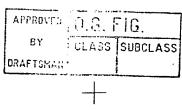
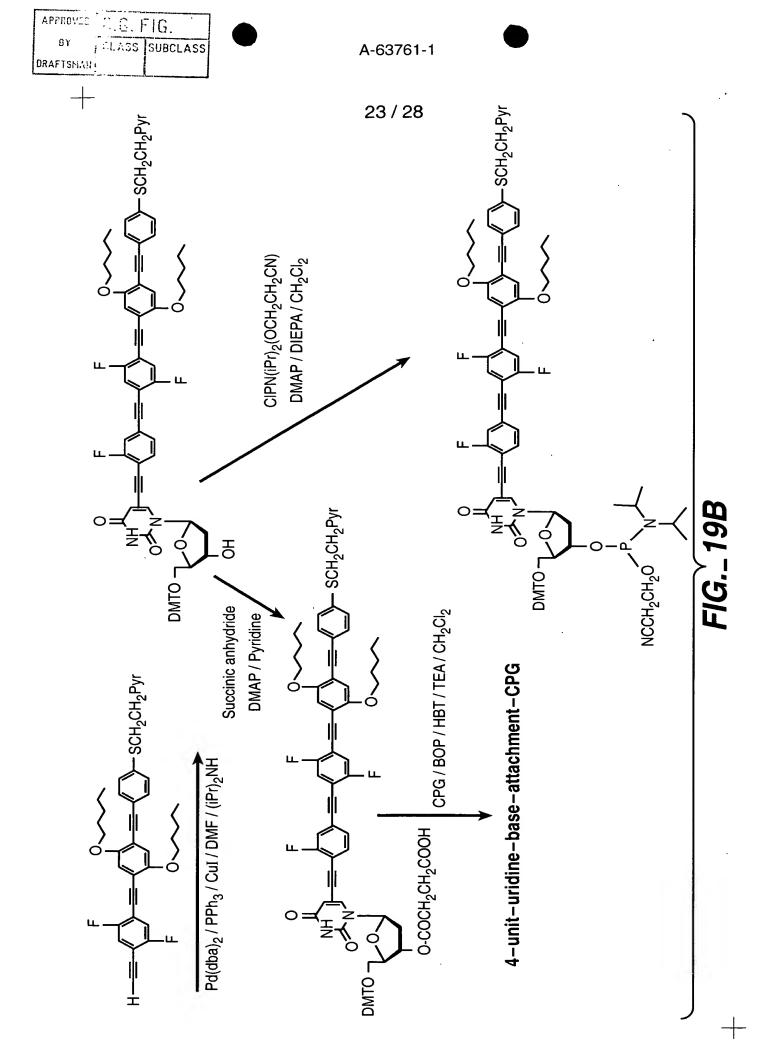
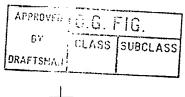
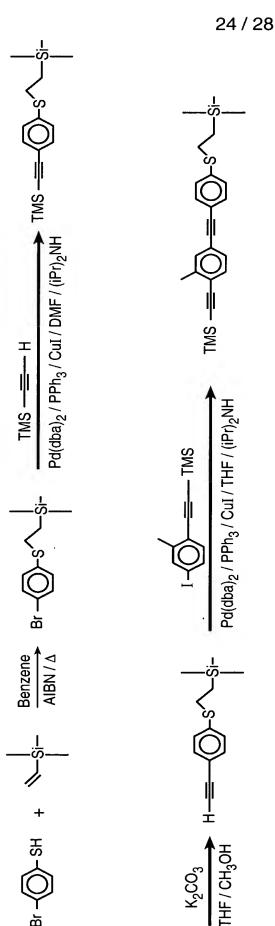


FIG.\_ 19A

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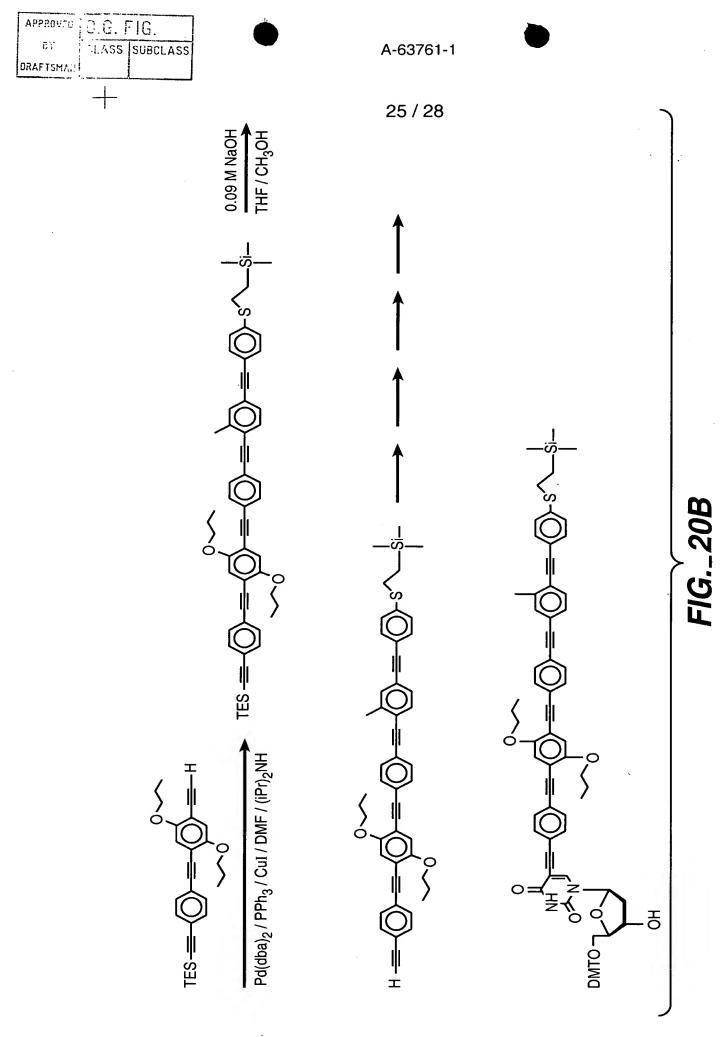




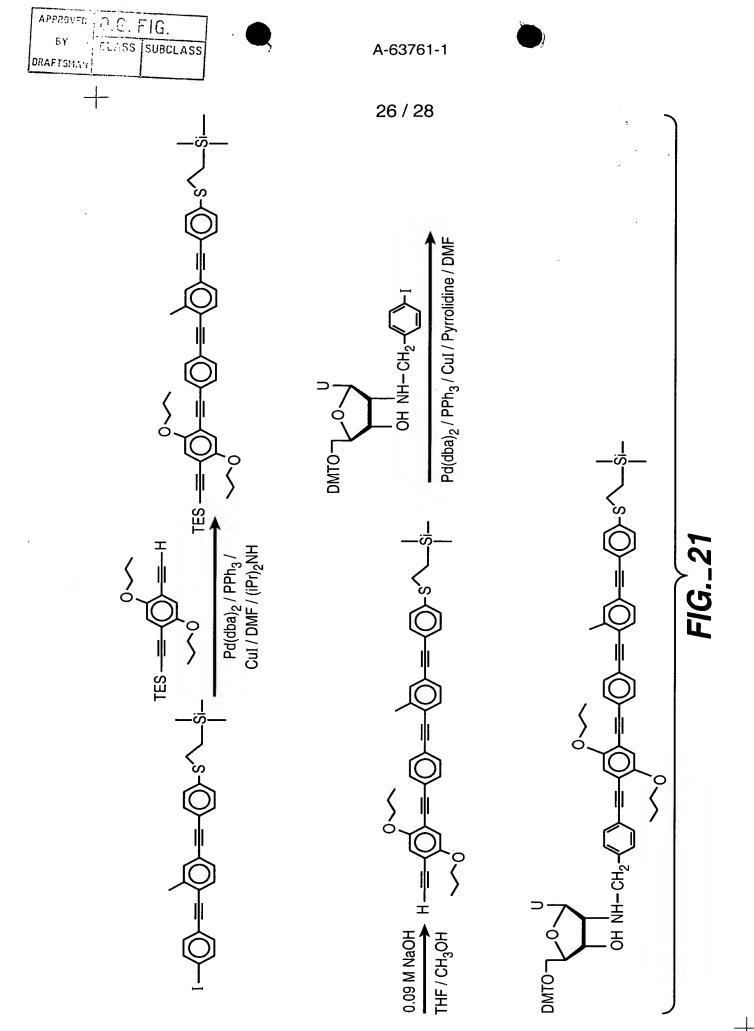


$$K_2CO_3$$
 $H = \bigcirc -Si$ 
 $CO_3 + CH_3OH$ 
 $CO_3 + CH_3OH$ 

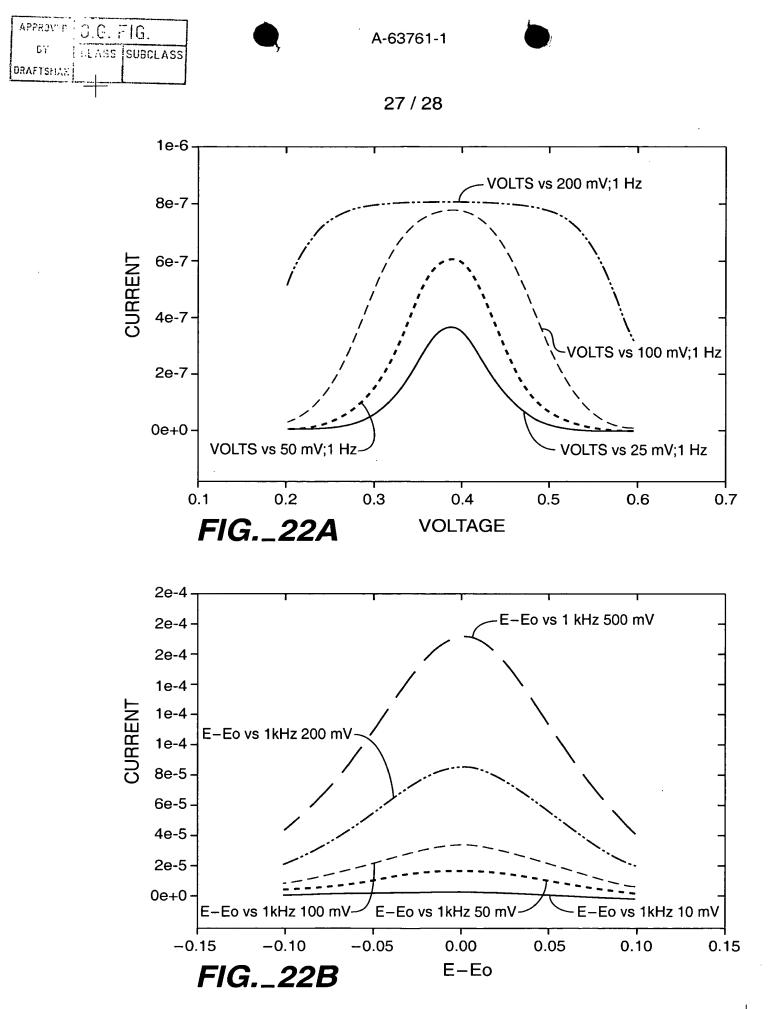
FIG.\_20A



 $\perp$ 



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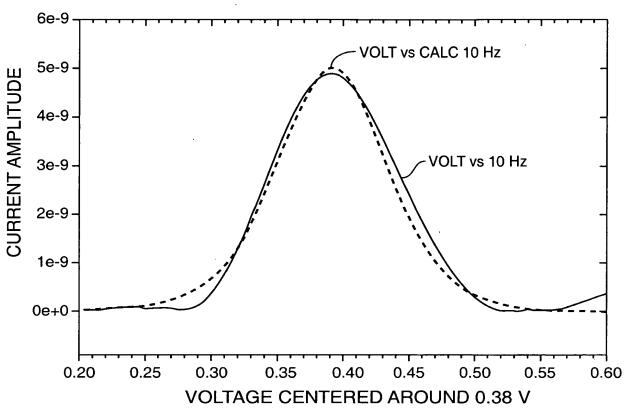


FIG.\_23A

